SCH<sub>3</sub>

FIG.\_1

BY

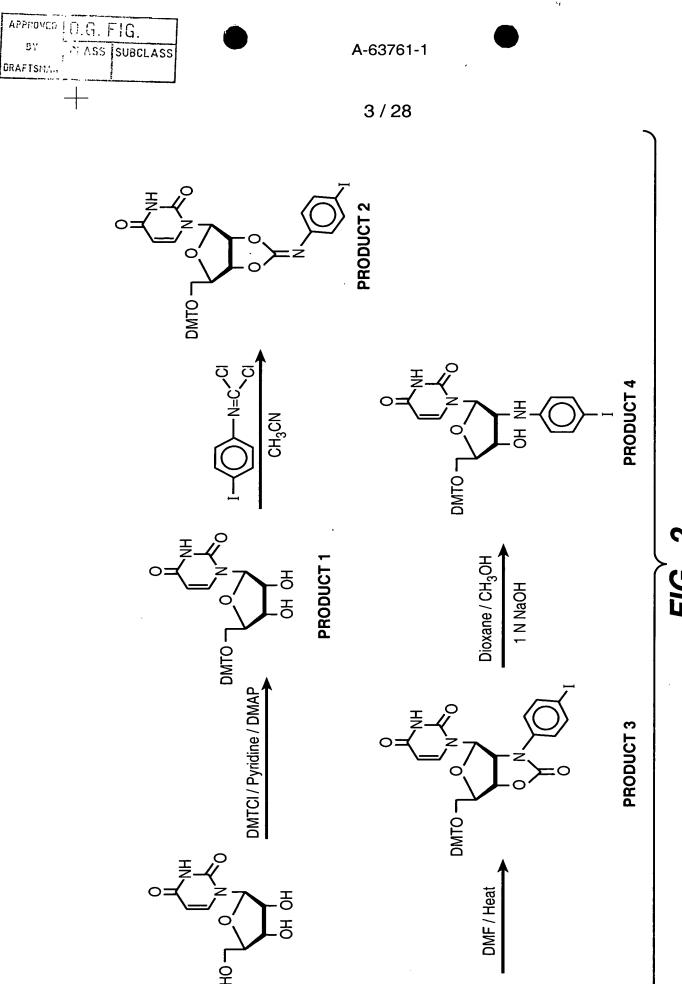
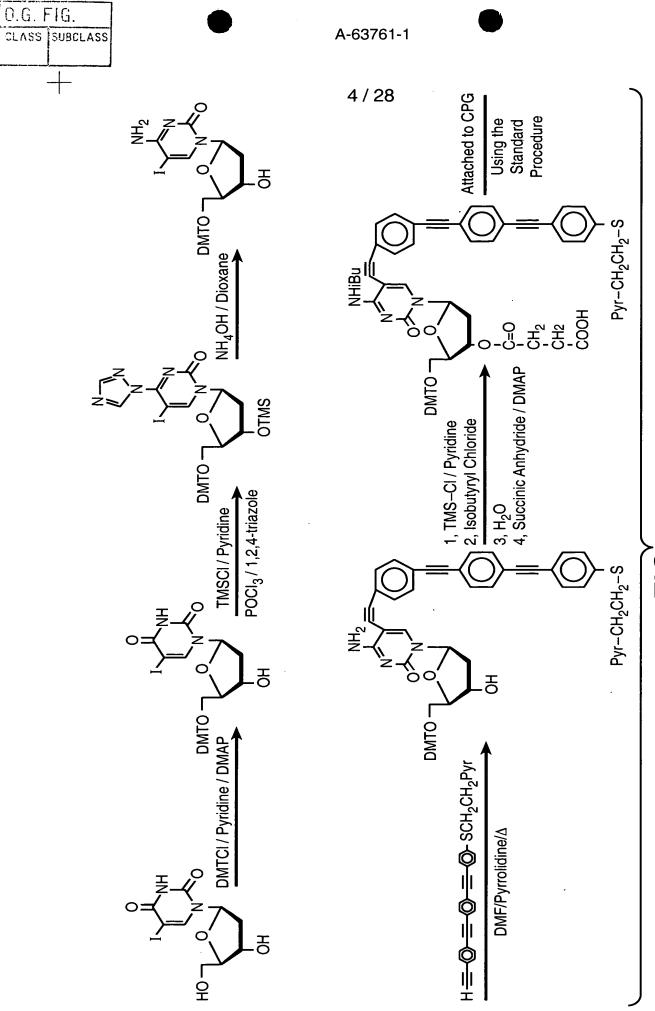
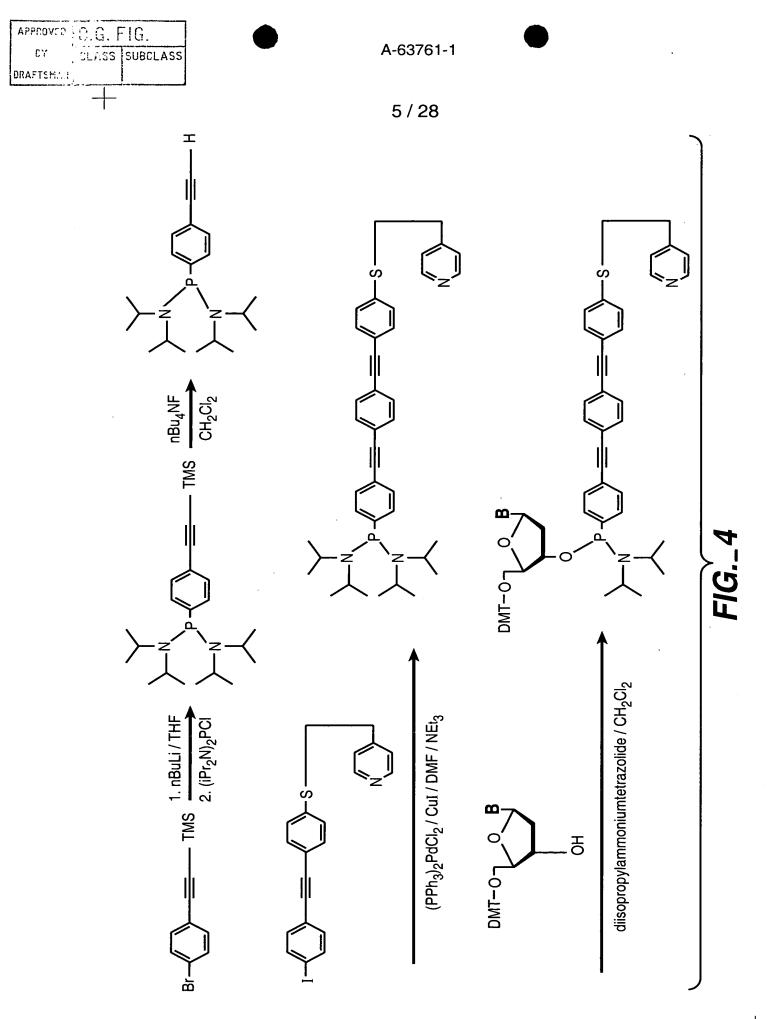


FIG.\_2

PROVLO

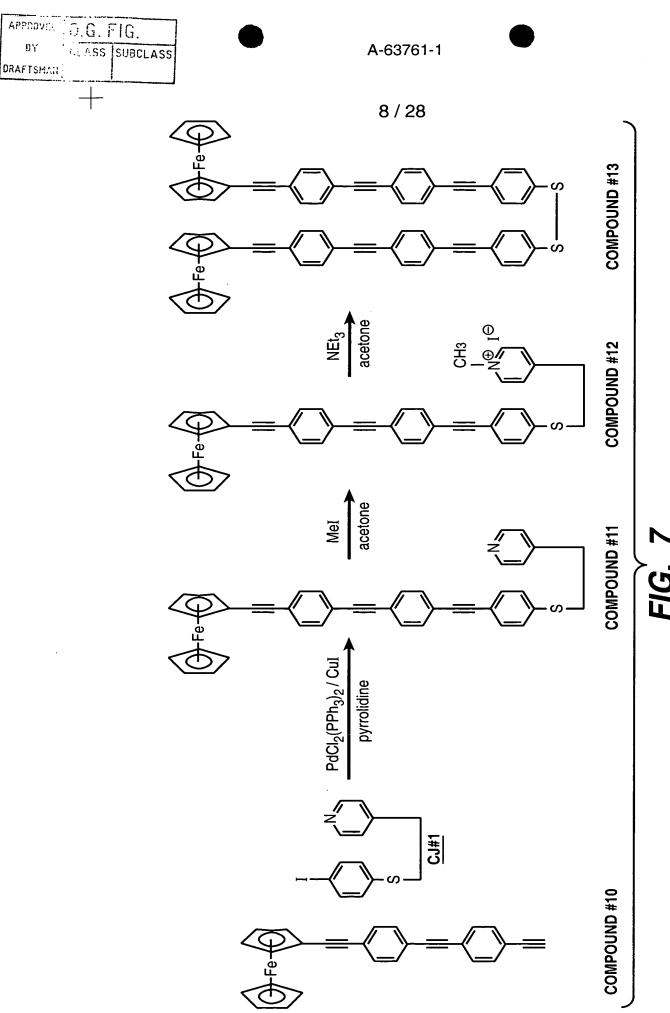
81 FTSHAH

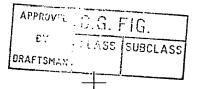




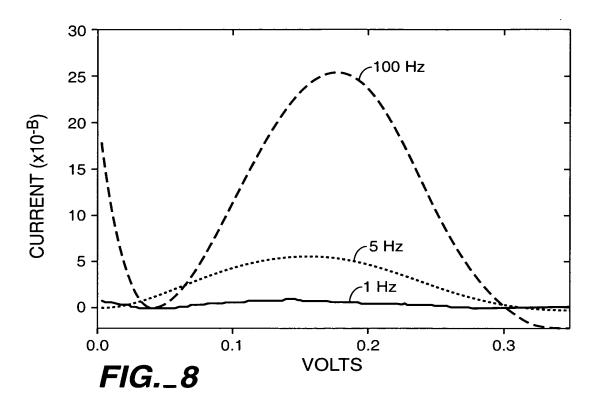
╬

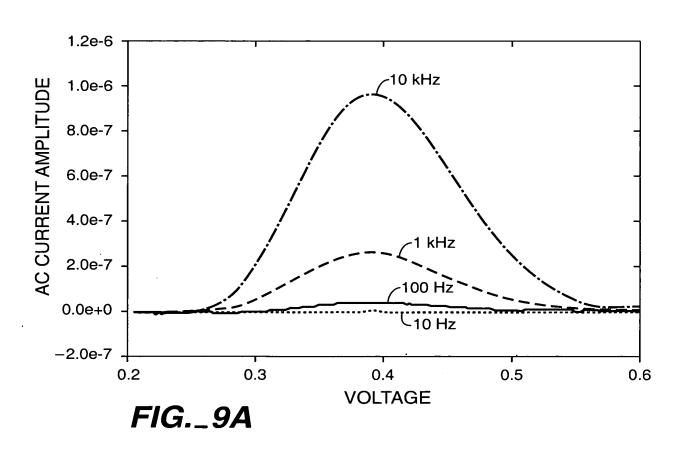
FIG.\_5

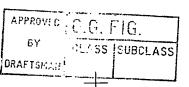




A-63761-1







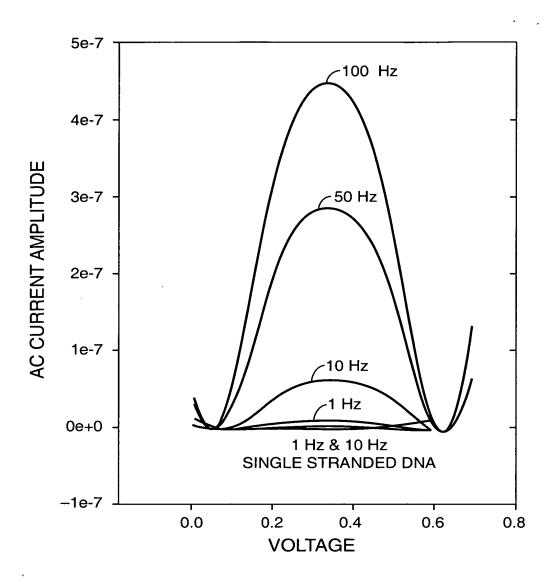
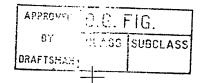
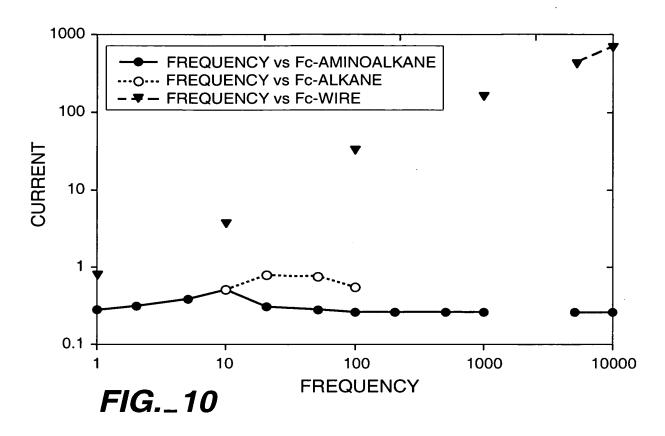
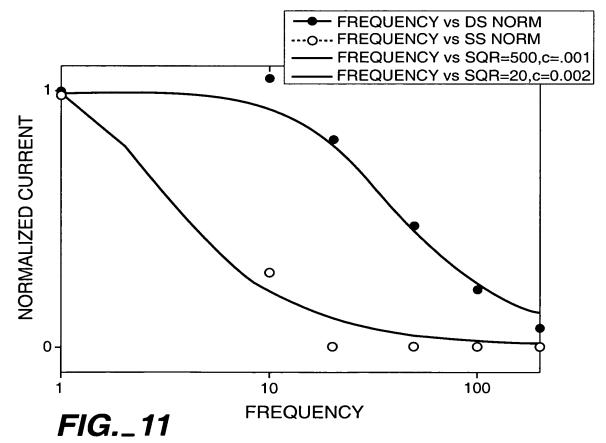
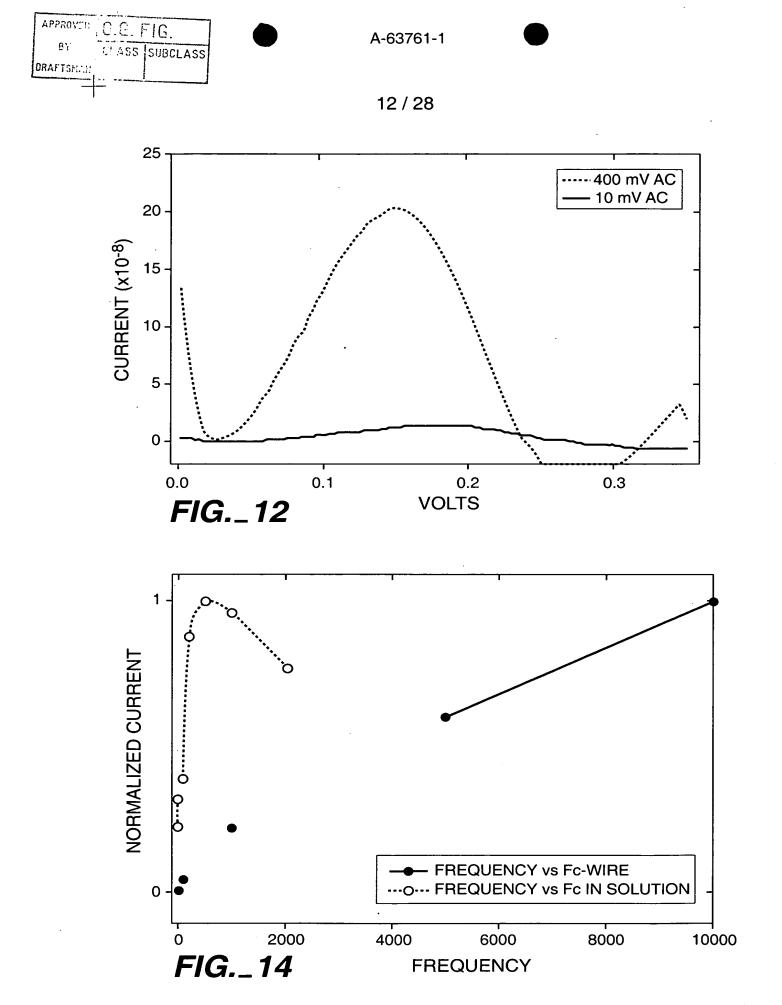


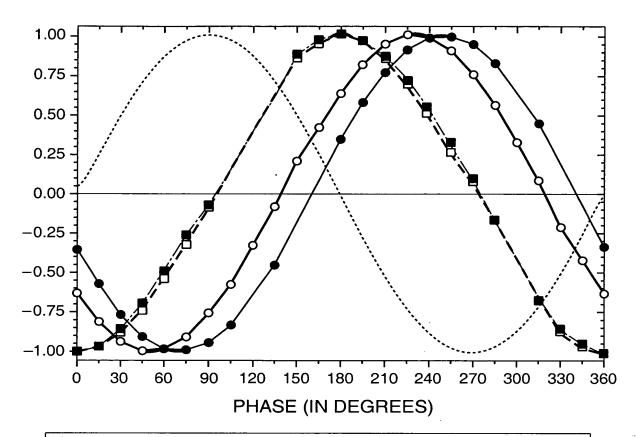
FIG.\_9B











- -O- Fc-ALKANE + HO-INSULATOR(#1) [0213\_21] MAX @ 182 DEG.
- Fc-ALKANE + HO-INSULATOR (#2) [0213\_55] MAX @ 179 DEG.
- -D Fc-WIRE (DISULFIDE) + HO-INSULATOR, 2-STEP PROCESS [g010901]

MAX @ 230 DEG.

─■─ Fc-WIRE (PROTECTED) + HO-INSULATOR,

3 STEP PROCESS [g010834]

MAX @ 250 DEG.

····· DRIVING FORCE

FIG.\_15A

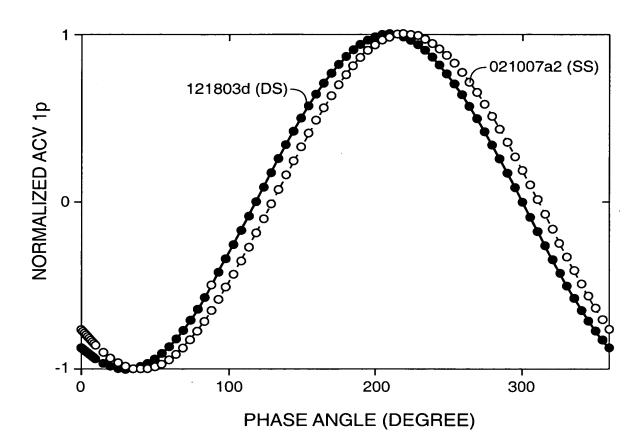
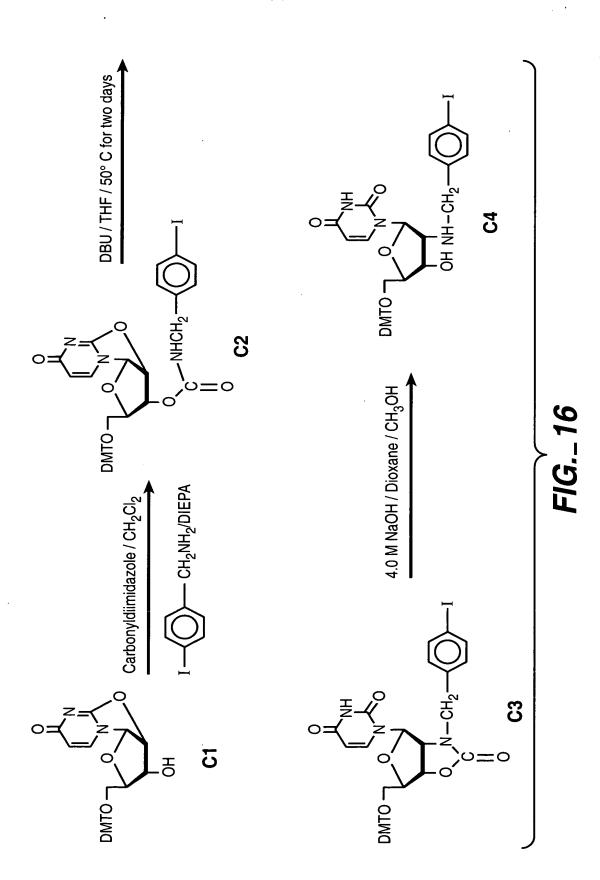
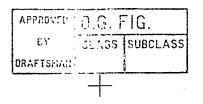


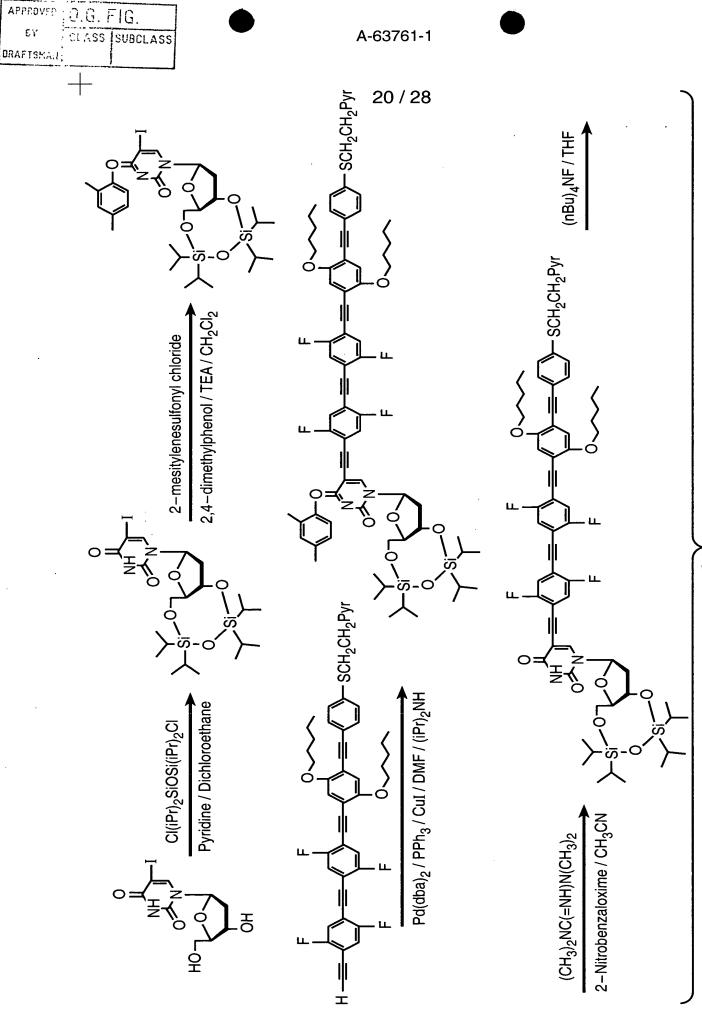
FIG.\_15B





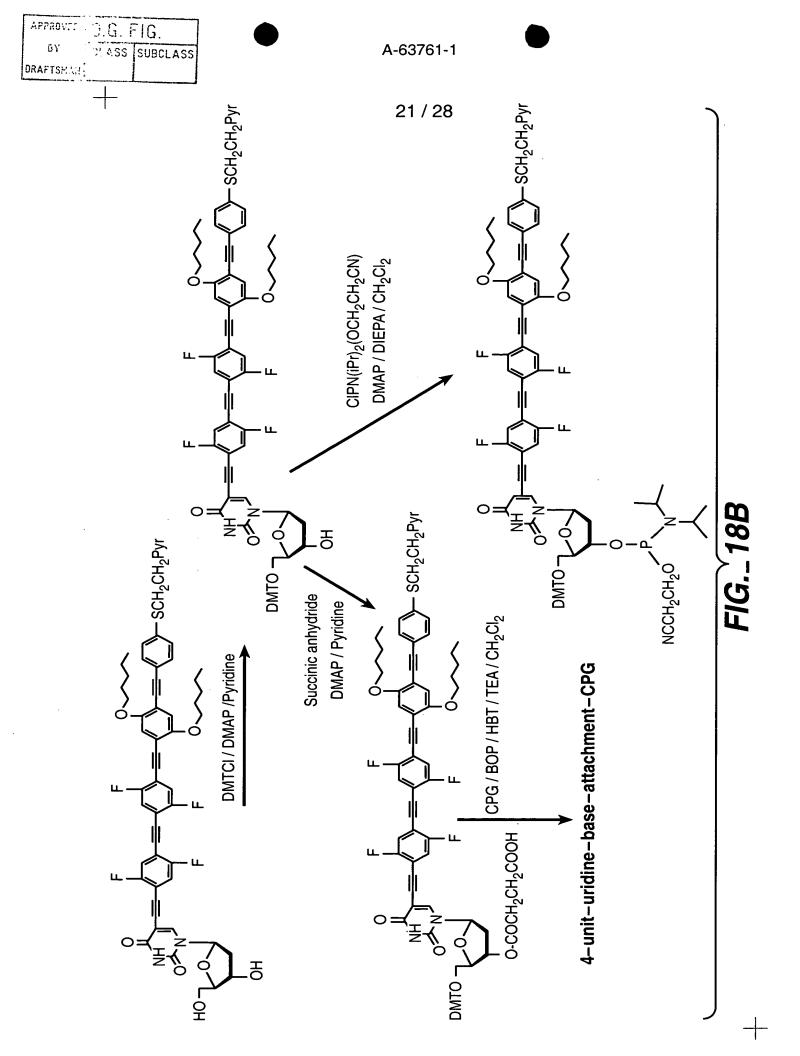
 $\perp$ 

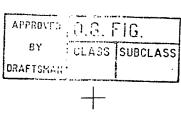
FIG.\_17F

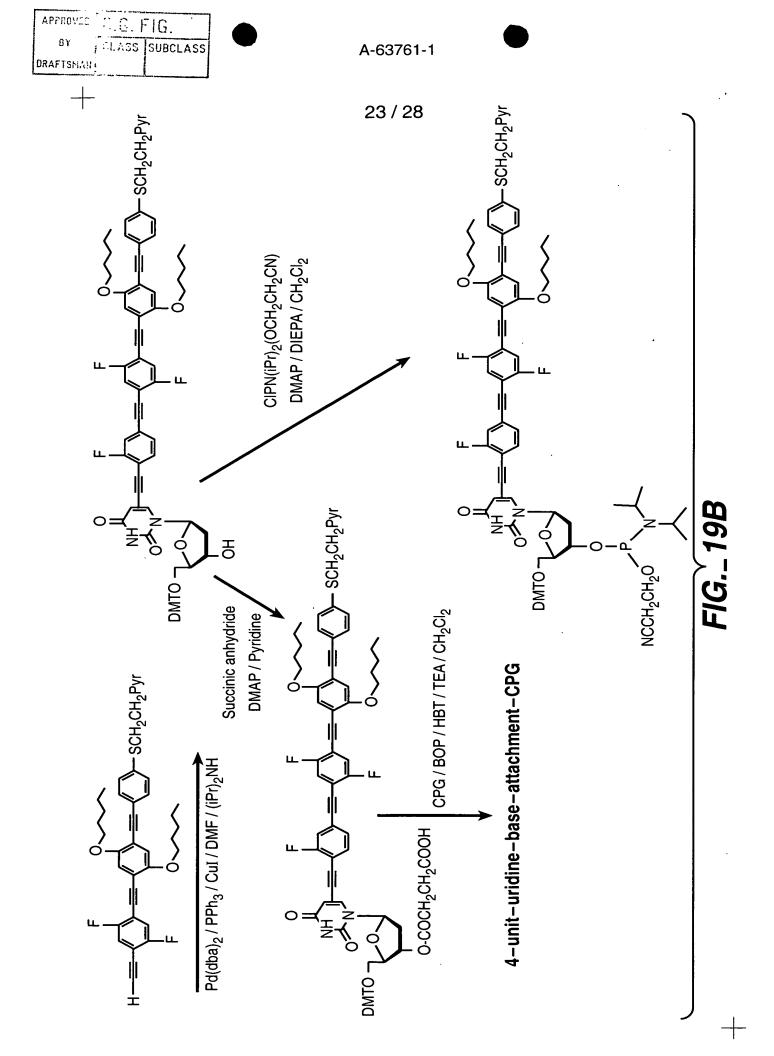


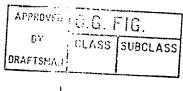
£¥

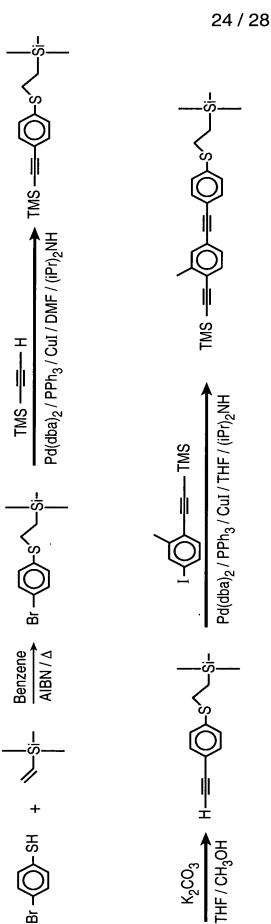
FIG. 18A











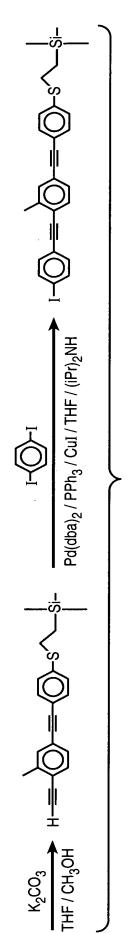
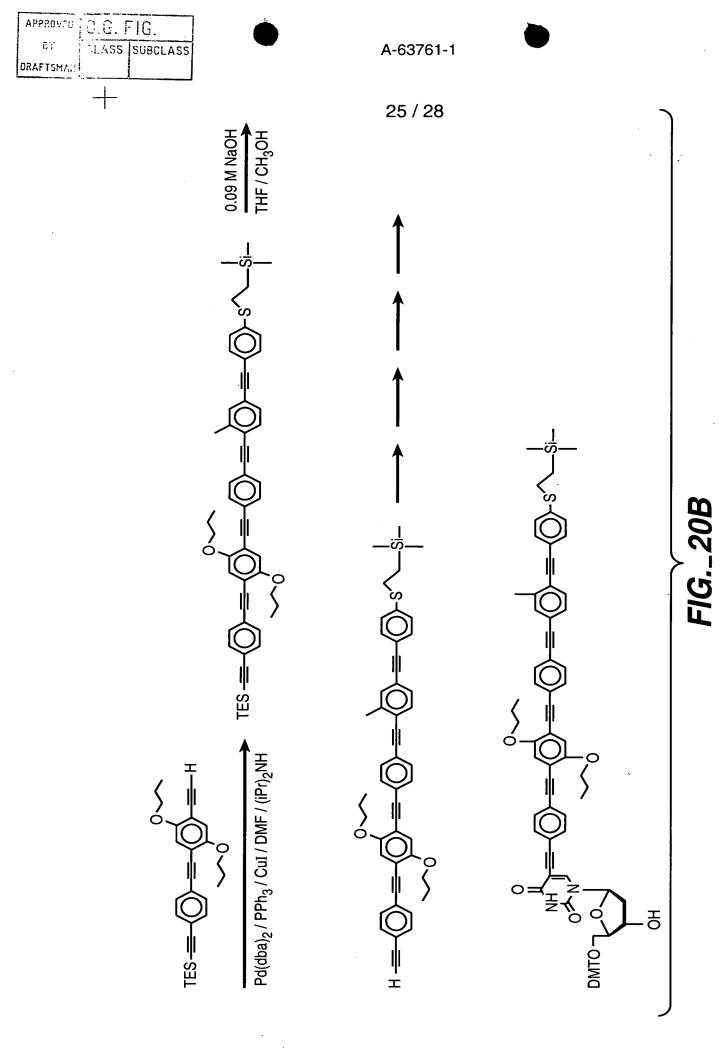
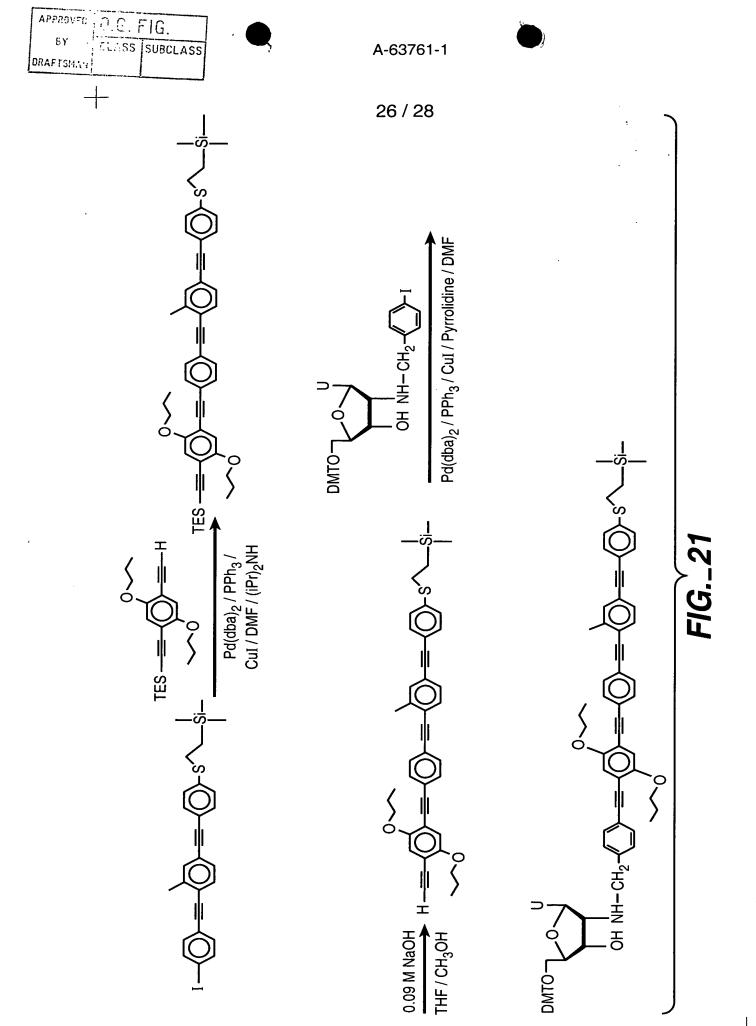
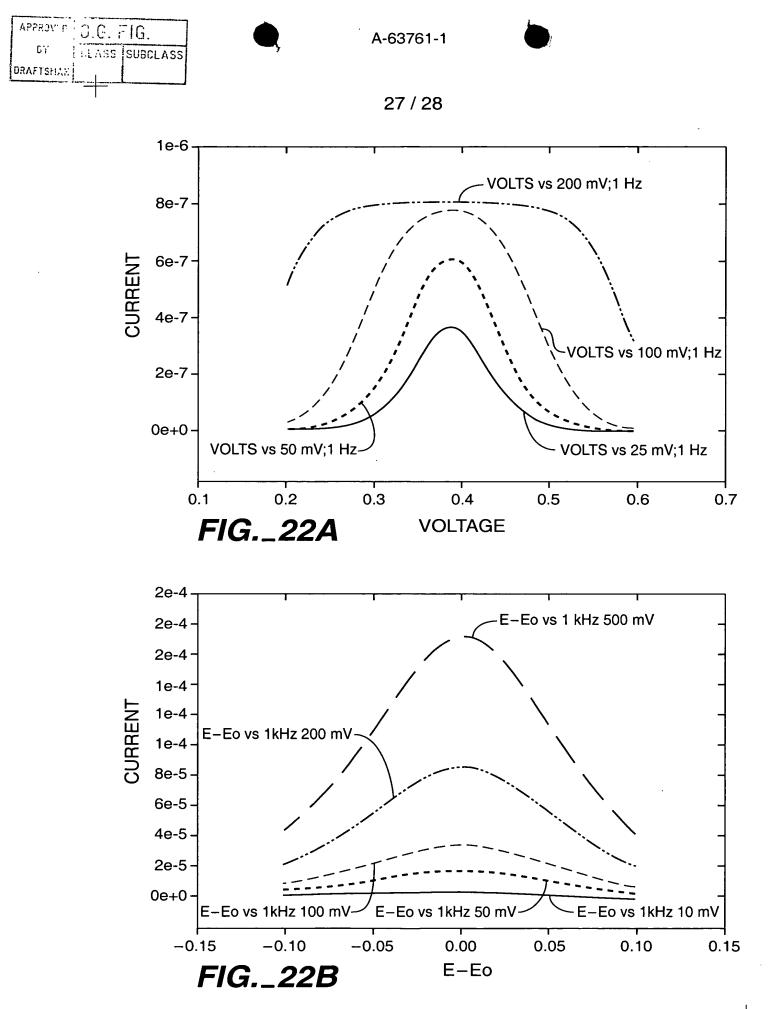


FIG.\_20A







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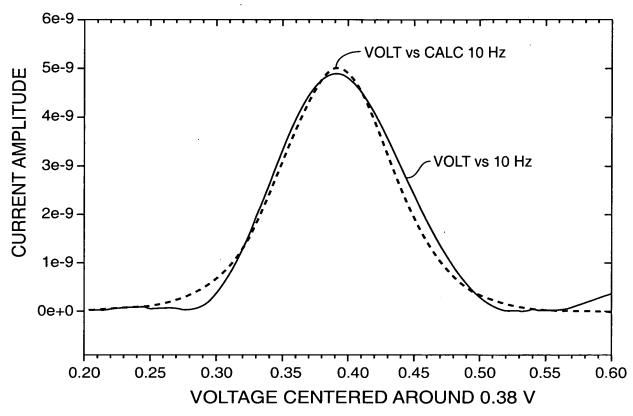


FIG.\_23A

